

A Semi-Lagrangian Deterministic Solver for the Semiconductor Boltzmann-Poisson System

José A. Carrillo^{1,*}, Armando Majorana² and Francesco Vecil³

¹ ICREA (Institució Catalana de Recerca i Estudis Avançats) and Departament de Matemàtiques, Universitat Autònoma de Barcelona, E-08193 Bellaterra, Spain.

² Dipartimento di Matematica e Informatica, Università di Catania, Catania, Italy.

³ Departament de Matemàtiques, Universitat Autònoma de Barcelona, E-08193 Bellaterra, Spain.

Received 30 October 2006; Accepted (in revised version) 29 January 2007

Communicated by Chi-Wang Shu

Available online 27 April 2007

Abstract. In this paper we develop a deterministic numerical method for solving the Boltzmann transport equation for semiconductors based on a transport-collision time-splitting method. Transport phases are solved by means of accurate flux-balance methods while collision steps are computed in the original k -grid. Numerical experiments are shown allowing for a discussion of this method with respect to other present in the literature.

AMS subject classifications: 65M99, 82D37, 82-08

Key words: Kinetic equations for semiconductors, semi-Lagrangian schemes, splitting schemes.

1 Introduction

The semi-classical Boltzmann transport equation (BTE) is a mesoscopic description of the transport/collision of charged particles in an electronic device and is given by

$$\frac{\partial f}{\partial t} + \frac{1}{\hbar} \nabla_k \varepsilon \cdot \nabla_x f - \frac{q}{\hbar} E \cdot \nabla_k f = \mathcal{Q}[f], \quad (1.1)$$

where $f(t, x, k)$ measures the probability density of finding an electron at time t in position x with wave vector k . The parameter \hbar is the Planck constant divided by 2π and q is the positive elementary charge.

*Corresponding author. *Email addresses:* carrillo@mat.uab.es (J. A. Carrillo), majorana@dmi.unict.it (A. Majorana), fvecil@mat.uab.es (F. Vecil)

The band structure of the semiconductor crystal is described by the energy-band function which can be approximated by a parabolic function given by

$$\varepsilon(k) = \frac{1}{2} \frac{\hbar^2}{m^*} |k|^2, \quad (1.2)$$

where m^* is the effective electron mass. In a first step, we shall consider the most important scattering mechanisms in Si: acoustic phonon scattering, in its elastic approximation, and optical phonon scattering with a single frequency ω . Therefore, the structure of the collision operator [20,24] is

$$\begin{aligned} \mathcal{Q}[f](t,x,k) &= \int_{\mathbb{R}^3} [S(k',k)f(t,x,k') - S(k,k')f(t,x,k)] dk' \\ &= \int_{\mathbb{R}^3} S(k',k)f(t,x,k') dk' - f(t,x,k) \int_{\mathbb{R}^3} S(k,k') dk' \\ &= \mathcal{Q}^+[f] - \mathcal{Q}^-[f] \end{aligned} \quad (1.3)$$

with

$$S(k,k') = K [(n_q + 1)\delta(\varepsilon(k') - \varepsilon(k) + \hbar\omega) + n_q\delta(\varepsilon(k') - \varepsilon(k) - \hbar\omega)] + K_0\delta(\varepsilon(k') - \varepsilon(k)), \quad (1.4)$$

where n_q is the occupation number of phonons

$$n_q = \frac{1}{\exp\left(\frac{\hbar\omega}{k_B T_L}\right) - 1}, \quad (1.5)$$

k_B is the Boltzmann constant and T_L the lattice temperature. The kernel K_0 is

$$K_0 = \frac{k_B T_L E_{ac}^2}{4\pi^2 \hbar u_l^2 \rho_0}, \quad (1.6)$$

where E_{ac} is the deformation potential, u_l is the sound velocity and ρ_0 is the crystal density. The kernel K is

$$K = \frac{D_i k^2}{8\pi^2 \hbar \rho_0 \omega}, \quad (1.7)$$

where ω is the frequency and $D_i k$ is the optical coupling constant. The self-consistent electrostatic field is computed through Poisson's equation

$$\Delta\Phi = \frac{q}{\epsilon} [\rho(t,x) - N_D(x)], \quad (1.8)$$

where ρ is the electron density

$$\rho(t,x) = \int_{\mathbb{R}^3} f(t,x,k) dk, \quad (1.9)$$